# AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

# Listing of Claims:

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 (Currently Amended) A multilayer structure formed on a glass or plastic substrate for shading ultraviolet and infrared light, comprising:

two or three layers of Ag;

two or three layers of indium tin oxide (ITO); and

dielectric oxide layers ranging from two layers to four layers,

wherein at-least two AG layers are <u>alternately</u> formed to be in contact with the <u>two</u> ITO layer <u>layers</u>, and the other Ag layer is formed to be in contact with the substrate; as an upward or downward layer.

wherein one of the dielectric layers is a top layer from the substrate; and wherein each dielectric oxide layer is made of a material which is selected from SiO<sub>2</sub>.

Al<sub>2</sub>O<sub>3</sub> ZrO<sub>2</sub>, Y<sub>2</sub>O<sub>3</sub>, and Ta<sub>2</sub>O<sub>5</sub>.

# 2-3. Cancelled

4. (Currently Amended) The multilayer structure as recited in claim 1, wherein the multilayer structure has seven (7) layers of:

a first layer of Ag formed on the substrate, having a thickness of 5.79 at least 5.7 nm and a refractive index of 0.051 at least 0.05;

a second layer of Y<sub>2</sub>O<sub>3</sub> formed on the first layer, having a thickness of <del>85.56</del> at least <u>85.5</u> nm and a refractive index of <del>1.79581</del> at least 1.7;

a third layer of Ag formed on the second layer, having a thickness of 9.39 at least 9.3 nm and a refractive index of 9.951 at least 0.05;

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a fourth layer of ITO formed on the third layer, having a thickness of 71.91 at least 71.9

nm and a refractive index of 2.058 at least 2.05;

a fifth layer of Ag formed on the fourth layer, having a thickness of 12.82 at least 12.8 nm and a refractive index of 9.051 at least 0.05;

a sixth layer of ITO formed on the fifth layer, having a thickness of 36.14 at least 36.1 nm and a refractive index of 2.058 at least 2.05; and

a seventh layer of  $Y_2O_3$  formed on the sixth layer, having a thickness of 4.08 at least 4.0 nm and a refractive index of 1.79581 at least 1.7.

 (Currently Amended) The multilayer structure as recited in claim 1, wherein the multilayer structure has seven (7) layers of:

a first layer of Ag formed on the substrate, having a thickness of <u>at least 5.6 nm</u> and a refractive index of 0.0051 at least 0.005;

a second layer of ZrO<sub>2</sub> formed on the first layer, having a thickness of 63.84 at least 63.8 nm and a refractive index of 2.06576 at least 2.06;

a third layer of Ag formed on the second layer, having a thickness of 40.05 at least 10.0 nm and a refractive index of -0.051 at least 0.05;

a fourth layer of ITO formed on the third layer, having a thickness of 76.34 at least 76.3

nm and a refractive index of 2.058 at least 2.05;

a fifth layer of Ag formed on the fourth layer; having a thickness of 13.07 at least 13.0 nm and a refractive index of 0.051 at least 0.05;

a sixth layer of ITO formed on the fifth layer, having a thickness of 29.57 at least 29.5 nm and a refractive index of 2.058 at least 2.05; and

a seventh layer of ZrO<sub>2</sub> formed on the sixth layer, having a thickness of 9.58 at least 9.5 nm and a refractive index of 2.06576 at least 2.06.

# 6-8. Cancelled.

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- (Original) An article comprising the structure of claim 1 applied to a surface of a glass or plastic substrate.
- (Currently Amended) A window construction for ultraviolet and infrared shading comprising:

a substrate of glass or plastic material;

two or three layers of Ag;

two or three layers of indium tin oxide (ITO); and

dielectric oxide layers ranging from two layers to four layers,

wherein at least two Ag layers are <u>alternately</u> formed to be in contact with the <u>two</u> ITO layer layers, and the other Ag layer is formed to be in contact with the substrate; as an upward or downward-layer

wherein one of the dielectric layers is a top layer from the substrate; and wherein each dielectric oxide layer is made of a material which is selected from SiO<sub>2</sub>, Al<sub>2</sub>O<sub>3</sub>, ZrO<sub>2</sub>, Y<sub>2</sub>O<sub>3</sub>, and Ta<sub>2</sub>O<sub>5</sub>.

- Cancelled.
- 12. (Currently Amended) A safety glass comprising:

two transparent panes made of glass or plastic material;

a plastic sheet adhered between the two transparent panes, preventing the panes from shattering; and

an optical coating formed on at least one of the transparent panes against the plastic sheet, for shading ultraviolet and infrared light, comprising:

two or three layers of Ag;

two or three layers of indium tin oxide (ITO); and

dielectric oxide layers ranging from two layers to four layers[[,]];

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wherein at-least two Ag layers are <u>alternately</u> formed to be in contact with the <u>two</u> ITO layer layers, and the other Ag layer is formed to be in contact with the substrate, as an upward or downward layer.

wherein one of the dielectric layers is a top layer from the pane; and wherein each dielectric oxide layer is made of a material which is selected from SiO<sub>2</sub> Al<sub>2</sub>O<sub>3</sub>, ZrO<sub>2</sub>, Y<sub>2</sub>O<sub>3</sub>, and Ta<sub>2</sub>O<sub>5</sub>,

Cancelled.